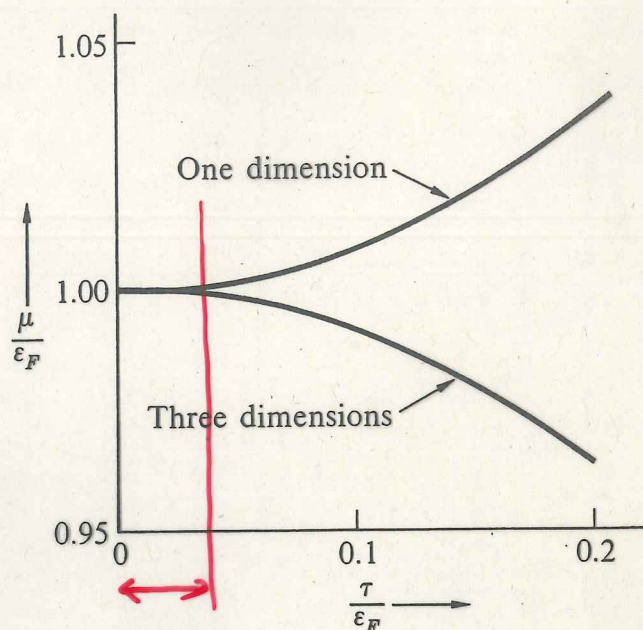


Figure 7.7 Variation with temperature of the chemical potential  $\mu$ , for free electron Fermi gases in one and three dimensions. In common metals  $\tau/\varepsilon_F \approx 0.01$  at room temperature, so that  $\mu$  is closely equal to  $\varepsilon_F$ . These curves were calculated from series expansions of the integral for the number of particles in the system.



We set

$$x \equiv (\varepsilon - \varepsilon_F)/\tau, \quad (31)$$

and it follows from (29) and (30) that

$$C_{el} = \tau \mathcal{D}(\varepsilon_F) \int_{-\varepsilon_F/\tau}^{\infty} dx x^2 \frac{e^x}{(e^x + 1)^2}. \quad (32)$$

We may safely replace the lower limit by  $-\infty$  because the factor  $e^x$  in the integrand is already negligible at  $x = -\varepsilon_F/\tau$  if we are concerned with low temperatures such that  $\varepsilon_F/\tau \sim 100$  or more. The integral\* becomes

$$\int_{-\infty}^{\infty} dx x^2 \frac{e^x}{(e^x + 1)^2} = \frac{\pi^2}{3}, \quad (33)$$

\* The integral is not elementary, but may be evaluated from the more familiar result

$$\int_0^{\infty} dx \frac{x}{e^{ax} + 1} = \frac{\pi^2}{12a^2}$$

on differentiation of both sides with respect to the parameter  $a$ .